

N THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.:

10/712,775

Group Art Unit:

FOR

1765

Filing Date:

November 14, 2003

Examiner:

Alanko, Anita Karen

Applicant:

Donggyun HAN et al.

Title:

METHOD

REMOVING

AND PHOTORESIST FROM A SUBSTRATE

Attorney Docket:

2557-000216/US

APPARATUS

Customer Service Window Randolph Building 401 Dulany Street Alexandria, VA 22314 **Mail Stop Amendment**

Date: October 24, 2007

AMENDMENT UNDER 35 U.S.C. §1.114

Sir:

In response to the Office Action mailed August 24, 2007, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

Amendments to the Claims begin on page 2 of this Amendment.

Remarks begin on page 8 of this Amendment.

No. of the second	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	36	•	50	=	0
Independent	3		4	=	0